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| APPLICATION | FILING or | GRP ART | | | | |
|-------------|-------------|---------|---------------|----------------|------------|------------|
| NUMBER | 371(c) DATE | UNIT | FIL FEE REC'D | ATTY.DOCKET.NO | TOT CLAIMS | IND CLAIMS |
| 10/553,491 | 04/18/2007 | 2131 | 12590 | P5104R1 | 104 | 33 |

9157 GENENTECH, INC. 1 DNA WAY

1 DNA WAY SOUTH SAN FRANCISCO, CA 94080 CONFIRMATION NO. 1304

FILING RECEIPT



Date Mailed: 11/08/2007

Receipt is acknowledged of this non-provisional patent application. The application will be taken up for examination in due course. Applicant will be notified as to the results of the examination. Any correspondence concerning the application must include the following identification information: the U.S. APPLICATION NUMBER, FILING DATE, NAME OF APPLICANT, and TITLE OF INVENTION. Fees transmitted by check or draft are subject to collection. Please verify the accuracy of the data presented on this receipt. If an error is noted on this Filling accept, please write to the Office of Initial Patent Examination's Filling Receipt Corrections. Please provide a copy of this Filling Receipt with the changes noted thereon. If you received a "Notice to File Missing Parts" for this application, please submit any corrections to this Filling Receipt with your reply to the Notice. When the USPTO processes the reply to the Notice, the USPTO will generate another Filling Receipt incorporating the requested corrections

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Assignment For Published Patent Application

GENENTECH, INC., SOUTH SAN FRANCISCO, CA

Power of Attorney: The patent practitioners associated with Customer Number 9157

Domestic Priority data as claimed by applicant

This application is a 371 of PCT/US04/11793 04/16/2004 which claims benefit of 60/463.656 04/16/2003

Foreign Applications

If Required, Foreign Filing License Granted: 11/06/2007

The country code and number of your priority application, to be used for filing abroad under the Paris Convention, is US 10/553,491

Projected Publication Date: 02/14/2008

Non-Publication Request: No

Early Publication Request: No

Title

Compositions and Methods Relating to Stop-1

Preliminary Class

370

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